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Tungsten surface temperature calculated by means of PIC simulations: bifurcation and space charge limited regime

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- Heat flux balance at the wall at each iteration $Q_p = Q_c$ With [1] $Q_c = J_s (2k_b T_s + B_w) + \epsilon \sigma T_s^4 + \frac{\kappa}{t} (T_s - T_0)$

 \rightarrow gives T_i and then J_i to be injected + loop until the steady state (T_0 = 300 K and wall thickness t=1 cm).

- 2 Simulation scenarios:

S1: The routine calculating T₁ and J₁ is run at the beginning of the simulations. During the establishment of the sheath, the surface receives a very large heat flux due to the electrons \rightarrow high T_c Then the wall eventually cools down to the steady state.

S2: The routine calculating T₁ and J₁ is launched after 10 plasma periods (waiting time) for the sheath to be established. The cathode can then be cold before the steady state is reached contrary to scenario 1.

Heat Flux & Fluid Approach and bifurcation

Sheath building & Space potential + plasma density

Sheath building and heat flux (S1)

- During the sheath building, the heat flux due to electrons is huge \rightarrow High Ts and strong Js \rightarrow Virtual cathode on several plasma periods (but can be temporary and cancels if further heat flux not large enough)

Ion and electron density profiles

- The reduction of κ makes the surface temperature increase with a larger thermionic emission \rightarrow sheath shrinking and double layer occurs = virtual cathode

Phase space and Velocity distribution

Averaged ion velocity

PIC Heat flux to the surface

William Andrew Publishing, Park Ridge, NJ, 1996 pp. 151 – 208 [2] Campanell and Umansky, Phys. Rev. Lett. 116, 085003 (2016)

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